

A Novel Route to Prepare Nano-Hg₂Cl₂ Arrays

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Recently, we find a novel route to prepare nano-Hg₂Cl₂ in the pores of alumina membrane. To the best of our knowledge, it is first time for preparing nano-Hg₂Cl₂ arrays. The nano-Hg₂Cl₂ has a potential application as nanoelectrode.

The ordered nanostructure materials have been attracting attention more and more recently, because of both their fundamental importance and the wide range of potential applications in nanodevices. Anodic alumina possesses uniform and paralleled porous structures and hence they have been used as an ideal template to prepare nanoparticle arrays extensively.¹⁻⁴ In this letter, we prepared nano-Hg₂Cl₂ arrays by porous alumina template.

A two-step anodization process as described previously fabricated the anodic alumina membrane (AAM).⁵ In brief, the high purity aluminum foil was anodized in oxalic acid, then the specimen was immersed in a mixture of H₃PO₄ and H₂CrO₄ to remove the alumina layers. Then, the aluminum foil was anodized again under the same conditions. At the bottom of the alumina membrane existed the remaining aluminum layer and a barrier layer of alumina existed between porous alumina and aluminum layer. The aluminum layer was removed by solution of CuCl₂. The barrier layer of alumina was removed by floating the alumina membrane on surface of 5% H₃PO₄.

The porous alumina membrane with ordered hole arrays was prepared (Figure 1). A layer of Au was sputtered onto

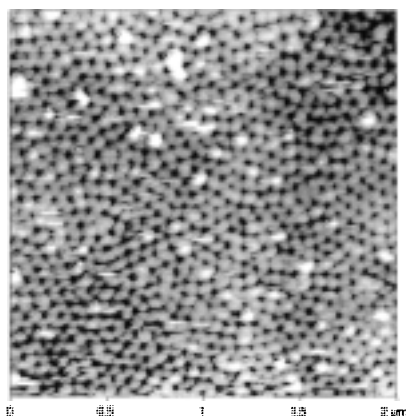


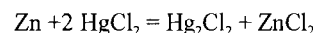
Figure 1. AFM image of surface of alumina. The aluminum was anodized in 0.3 M oxalic acid. The anodizing voltage was 20 V and temperature of electrolyte was kept constant at 5 °C.

one side of the membrane served as an electrode in a standard three-electrode electrochemical cell. The electrolyte contained 80g/L ZnSO₄·7H₂O and 20 g/L H₃BO₄. The electrodeposition was performed at 1.25 V relative to the Ag/AgCl reference electrode. After electrodepositing, the Zn nanowires were embedded in AAM⁶.

The alumina membrane with Zn nanowire arrays was immersed in a saturated HgCl₂ solution at the room temperature. In the pores of alumina membrane, the HgCl₂ was reduced to Hg₂Cl₂ by metal Zn and the Hg₂Cl₂ arrays were prepared.

The final sample was characterized by X-ray diffraction (XRD) and transmission electron microscopy (TEM). All peaks in XRD pattern (Figure 2) were indexed to the tetragonal phase of Hg₂Cl₂ with $a = 4.480 \text{ \AA}$, $c = 10.906 \text{ \AA}$, in good agreement with JCPDS No. 26-312. The TEM image (Figure 3) indicates that the nano-Hg₂Cl₂ constituted of spherical crystallites and the maximum diameter was about 70 nm, in agreement with the pore diameter of alumina membrane.

In reaction process, the formation of Hg₂Cl₂ is associated with the following



Here the metal Zn is a reductant, and the pores of alumina membrane are used to limit the size of nano-Hg₂Cl₂. The growth of Hg₂Cl₂ particles can be controlled by the pore diameter of alumina membrane.

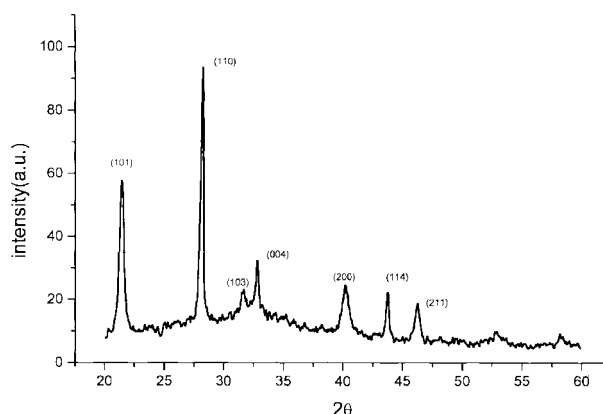


Figure 2. The XRD of Hg₂Cl₂ embedded in pores of porous alumina, operating on a Japan Rigaku DMAX-γ A X-ray diffraction with graphite-monochromatized Cu Kα radiation.

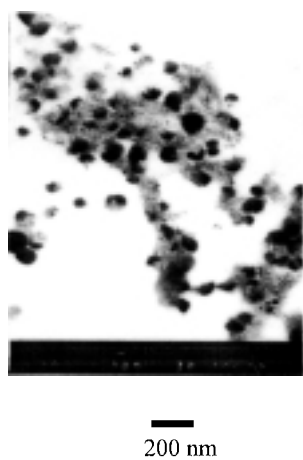


Figure 3. TEM image of Hg_2Cl_2 , Hitachi-800 transmission electron microscope using an accelerating voltage of 200 kV.

Further studies will be extended toward the following two directions: one is to change the pore diameter of alumina membrane for preparing the smaller nanoparticles in the pores of alumina membrane; the other is to utilize Zn to reduce the another compound to nanoparticles arrays in alumina membrane.

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